

10-18-05

1PW



PATENT  
Attorney's Docket No. 3521.182

ART UNIT: 2813

EXAMINER: Tuan H. Nguyen

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:  
SOMIT TALWAR et al.

Serial No.: 10/762,861

Filed: January 22, 2004

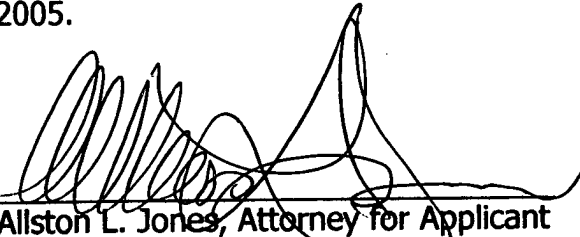
)  
)  
)  
)  
)  
)  
)

For: LASER THERMAL ANNEALING OF LIGHTLY DOPED SILICON SUBSTRATES

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**EXPRESS MAIL CERTIFICATE**

I hereby certify that this paper, and the listed enclosures, and fee is being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 on the date indicated below and is addressed to, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 with the Express Mail Label No. EV484314775US on October 17, 2005.

  
Allston L. Jones, Attorney for Applicant

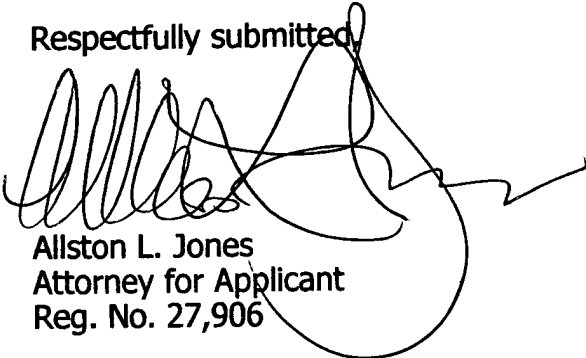
**TRANSMITTAL LETTER**

Transmitted herewith are the following documents:

1. Transmittal Letter in duplicate;
2. Response to Examiner's Restriction Requirement; and
3. Postcard.

If any fees are required with the filing of these documents, the Commissioner is authorized to charge such fees to Deposit Account No. 16-1331.

Respectfully submitted,



Allston L. Jones  
Attorney for Applicant  
Reg. No. 27,906

Date: October 17, 2005

Peters, Verny, Jones, Schmitt & Aston, L.L.P.  
425 Sherman Ave., Suite 230  
Palo Alto, CA 94306-1850  
Telephone No.:(650) 324-1677  
Attorney Docket No. 3521.182 (ALJ)